RISE KRISHNA SAI PRAKASAM GROUP OF INSTITUTIONS

(Approved by AICTE-NEW DELHI, Affiliated to JNTUK KAKINADA)
(An ISO 9001:2015 certified Institute)
NH-16, Valluru,-523272, Ongole, Prakasam District, A.P

DEPARTMENT OF COMPUTER SCIENCE AND ENGINEERING

Dt: 20th, Feb-2019

Intellectual property : copyright, Trademarks and patents

Objectives:

1. To develop **IPR Values** mind set in the students

2. To plan for Patents or Journals with clarity

3. To present with confidence

Outcomes:

1. Students have changed attitude towards **IPR Rights.**

2. Students got overview on Patents, Journals etc.

3. Leadership skills and Innovative thinking improved

4. Students are preparing for filing their Patents.

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Report:

Half-day session program on "**IPR Rights**" is conducted on 20ᵗʰ February, 2019 in RISE KRISHNA SAI PRAKASAM GROUP OF, ONGOLE. The Session is taken by **Mr. M. Janakiram**, Associate professor, MBA Department, EDC-Dean of PACEITS who had already filed 3 Patents. 90 facilities and 450 students attended the program in two sessions. He started teaching them about what is meant by **IPR Rights.** How to apply for a patent and what are the rules for applying a patent. He also explained about how to write the IEEE papers, Journals etc. The students also enjoyed the session a lot and it created a great impact in them to come up with new ideas and applying it for the patent.

HoD